Honeywell Docket No. H0005567,36146 - 4780 Buchalter Docket No. H9930-0305

IN THE CLAIMS

(Previously Presented) An absorbing composition comprising at least one
inorganic-based compound, at least one absorbing compound, and at least one
material modification agent, wherein the at least one material modification agent
comprises at least one adhesion promoter, at least one crosslinking agent, at least
one porogen, at least one catalyst, at least one capping agent, at least one pH
tuning agent or a combination thereof, wherein the at least one adhesion promoter
comprises APTEOS triflate, APTEOS methanesulfonate, APTEOS nitrate, APTEOS
nfbs, ammonium triflate, ammonium nfbs, ammonium methanesulfonate,
ammonium nitrate, TMAH triflate, TMAH nfbs, TMAH methanesulfonate, TMAA,
TMAN. TMAH nitrate or a combination thereof.

Canceled.

- (Original) The composition of claim 1, wherein the absorbing compound is an organic-based compound.
- (Original) The composition of claim 1, wherein the absorbing compound strongly absorbs light over at least an approximately 0.5 nm wide wavelength range at wavelengths less than 375 nm.
- (Original) The composition of claim 1, wherein the absorbing compound strongly absorbs light over at least an approximately 10 nm wide wavelength range at wavelengths less than 375 nm.
- (Original) The composition of claim 4, wherein the range comprises wavelengths less than about 260 nm.
- (Original) The composition of claim 1, wherein the absorbing compound comprises
 at least one benzene ring and a reactive group selected from the group comprising
 hydroxyl groups, amine groups, carboxylic acid groups and substituted silyl groups.
- (Original) The composition of claim 7, wherein the absorbing compound comprises two or more benzene rings.
- 9. (Original) The composition of claim 8, wherein the two or more benzene rings are

Honeywell Docket No. H0005567.36146 - 4780 Buchalter Docket No. H9930-0305

fused.

- 10. (Original) The composition of claim 7, wherein the organic absorbing compound comprises an absorbing compound comprising anthraflavic acid, 9-anthracene carboxylic acid, 9-anthracene methanol, alizarin, quinizarin, primuline, 2-hydroxy-4(3-triethoxysilylpropoxy)-diphenylketone, rosolic acid, triethoxysilylpropyl-1,8-naphthalimide, 9-anthracene carboxy-alkyl triethoxysilane, phenyltriethoxysilane, 10-phenanthrene carboxy-methyl triethoxysilane, 4-phenylazophenol, 4-ethoxyphenylazobenzene-4-carboxy-methyl triethoxysilane, 4-methoxyphenylazobenzene-4-carboxy-methyl triethoxysilane or mixtures thereof.
- (Original) The composition of claim 1, wherein the inorganic-based compound comprises a silicon-based compound.
- (Original) The composition of claim 11, wherein the silicon-based compound comprises a polymer.
- 13. (Original) The composition of claim 12, wherein the polymer comprises an organosiloxane compound, such as methylsiloxane, methylsilosane, phenylsiloxane, phenylsilosane, phenylsilosane, acrylic siloxane polymers, methylphenylsiloxane, methylphenylsilosane, silicate polymers, silazane polymers or mixtures thereof.
- 14. (Previously Presented) The composition of claim 12, wherein the polymer comprises hydrogensiloxane, hydrogensilsesquioxane, organohydridosiloxane, silsesquioxane-based compounds, derivatives of silicic acid and organohydridosiloxane polymers; copolymers of hydrogensilsesquioxane and an alkoxyhydridosiloxane, hydroxyhydridosiloxane, derivatives of silicic acid or mixtures thereof.
- 15. (Original) The composition of claim 12, wherein the polymer is of a general formula comprising (H_{0-1.0}SiO_{1.5-2.0})_x, where x is greater than about 4, and (H_{0-1.0}SiO_{1.5-2.0})_n(R_{0-1.0}SiO_{1.5-2.0})_n, where m is greater than 0, the sum of n and m is from about 4 to about 5000 and R is a C₁-C₂₀ alkyl group or a C₆-C₁₂ aryl group.

Honeywell Docket No. H0005567.36146 - 4780 Buchalter Docket No. H9930-0305

Claims 16-17: Canceled.

 (Previously Presented) The composition of claim 1, wherein the at least one adhesion promoter further comprises phosphorus.

Claims 19-25: Canceled.

- (Previously Presented) The composition of claim 1, wherein the at least one adhesion promoter further comprises an acid.
- (Previously Presented) The composition of claim 1, the at least one adhesion promoter further comprises a neutral compound.
- (Previously Presented) The composition of claim 1, wherein the at least one adhesion promoter further comprises a weak acid.
- (Previously Presented) The composition of claim 1, wherein the at least one adhesion promoter further comprises a resin-based material.
- (Original) The composition of claim 29, wherein the resin-based material comprises
 at least one of a phenolic-containing resin, a novolac resin, an organic acrylate resin
 or a styrene resin.
- 31. (Previously Presented) The composition of claim 1, wherein the adhesion promoter further comprises a polydimethylsiloxane-based material, an alkoxy or hydroxycontaining silane monomer, a vinyl-containing silane monomer, an acrylated silane monomer or a silyl hydride compound.

Claims 32-36: Canceled.

(Previously Presented) The composition of claim 1, wherein the at least one
porogen further comprises a catalyst and wherein the catalyst comprises TMAA,
TMAN, TBAA, TBAN, CTAA, CTAN or a combination thereof.

Claims 38-58: Canceled.